

External_Type	Material_Group	Substances	CAS_Number	Mass	Mass_Percentage_in_Leaf	Massmg
Die	Doped silicon	Silicon (Si)	7440-21-3	1.44635	100.0	1.7
Subtotal				1.44635	100	1.7
Wire	Impurity	Non hazardous		0.00001	0.01	0.00002
	Pure metal	Copper (Cu)	7440-50-8	0.13399	99.99	0.15748
Subtotal				0.134	100	0.1575
Die Attach		Aromatic Polyester Resin	60088-52-0	0.00277	2.5	0.00325
		Paraffin wax	8002-74-2	0.00774	7.0	0.0091
		Epoxy resin system		0.02212	20.0	0.026
		Silver (Ag)	7440-22-4	0.07798	70.5	0.09165
Subtotal				0.11061	100	0.13
Lead Frame	Copper alloy	Phosphorous (P)	7723-14-0	0.02597	0.05	0.03053
	Copper alloy	Zinc (Zn)	7440-66-6	0.05194	0.1	0.06105
	Copper alloy	Iron (Fe)	7439-89-6	1.19464	2.3	1.40415
	Copper alloy	Copper (Cu)	7440-50-8	50.66832	97.55	59.55427
Subtotal				51.94087	100	61.05
Post-plating	Lead alloy	Tin (Sn)	7440-31-5	0.48495	100.0	0.57
Subtotal				0.48495	100	0.57
Mould Compound	Polymer	Phenol Formaldehyde resin (generic)	9003-35-4	0.68825	1.5	0.80895
	Polymer	Epichlorohydrin/Diethyleneglycol Epoxy resin (generic)	25928-94-3	4.35891	9.5	5.12335
	Filler	Silica fused	60676-86-0	40.37724	88.0	47.4584
	Carbon Black	Carbon black	1333-86-4	0.45883	1.0	0.5393
Subtotal				45.88323	100	53.93
Total				100.00001	100	117.5375

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